

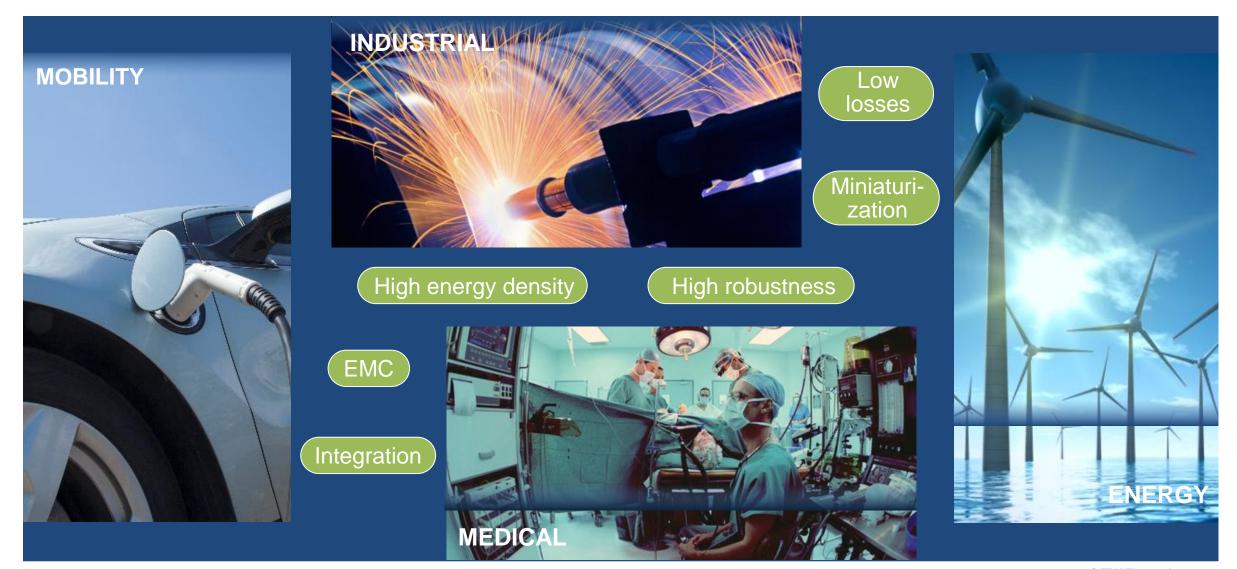
### IEEE PSMA Capacitor Committee Workshop 2020

# Innovative film capacitor technologies for wide band-gap semiconductors

Advanced design features for high-frequency applications

Manuel Gómez manuel.gomez@tdk-electronics.tdk.com Aluminium & Film Capacitors Business Group Málaga, Spain April 28, 2020

### **Growing demands challenging power electronics**

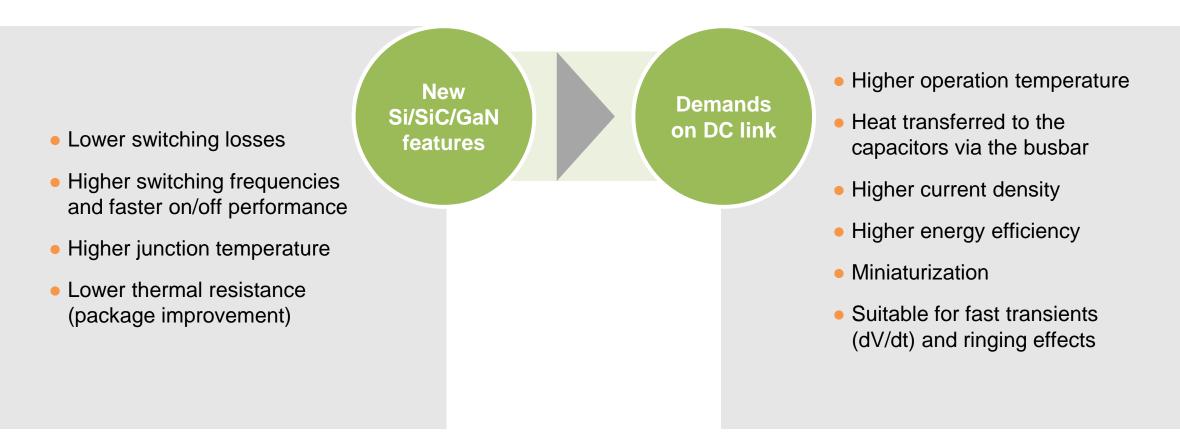


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## Advanced semiconductors put high demands on the DC link



#### Challenge for passive components: Not be the bottleneck in new power electronics designs

## **Design goals for high-frequency capacitors**

#### High operating temperature

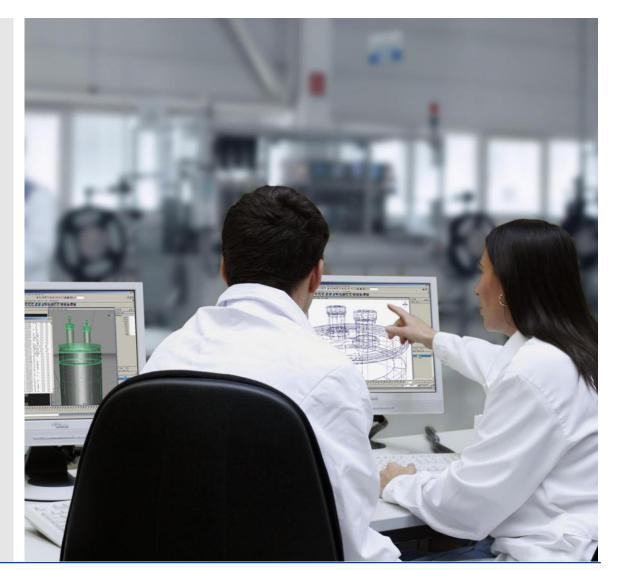
- High temperature dielectric
- Handle heat coming from the semiconductor busbar
- High current capability

#### Low ESR vs frequency

- Minimized losses
- Wider operation bandwidth up to the MHz range
- Good performance close and above the resonance frequency

#### Low ESL of <10 nH

- Internal design for high dV/dt levels
- Make snubber capacitors unnecessary

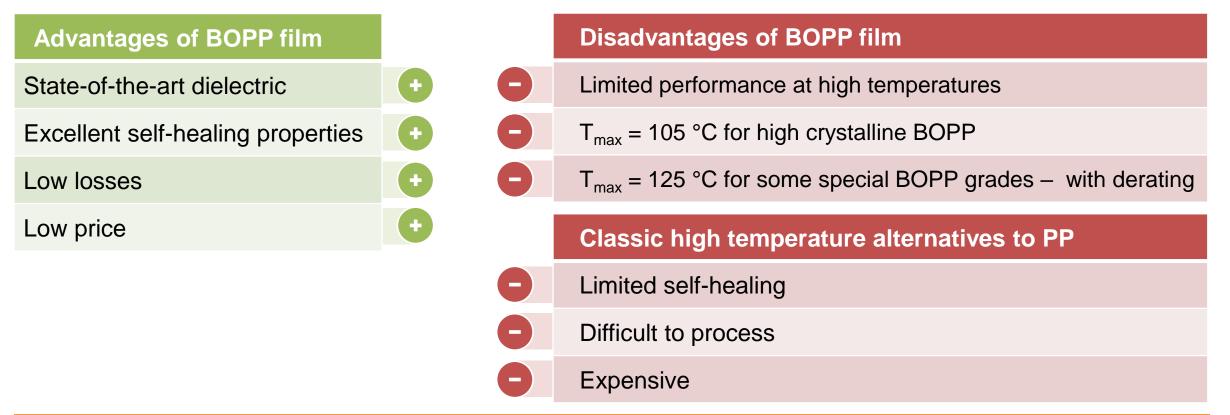


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## New dielectric for high temperature is needed

**Polypropylene** (PP) is a commonly used standard dielectric in film capacitors. PP is transformed into a **biaxially oriented PP (BOPP) film** in a sequential stretching process

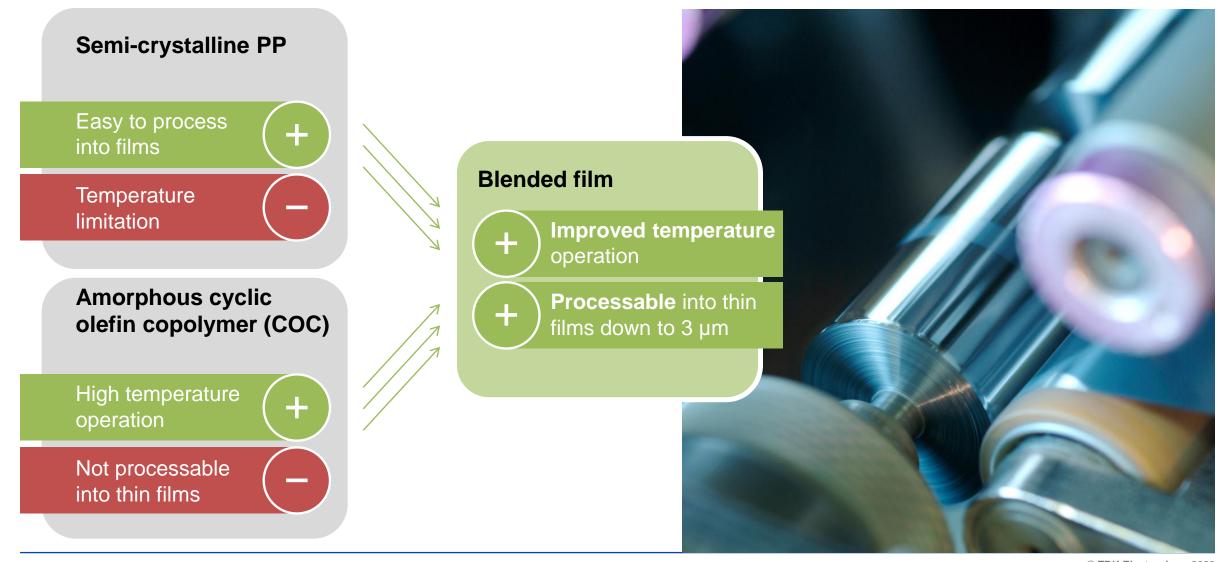


Polypropylene is reaching its limits due to the rising demands of new wide band-gap semiconductors, especially in high-temperature applications

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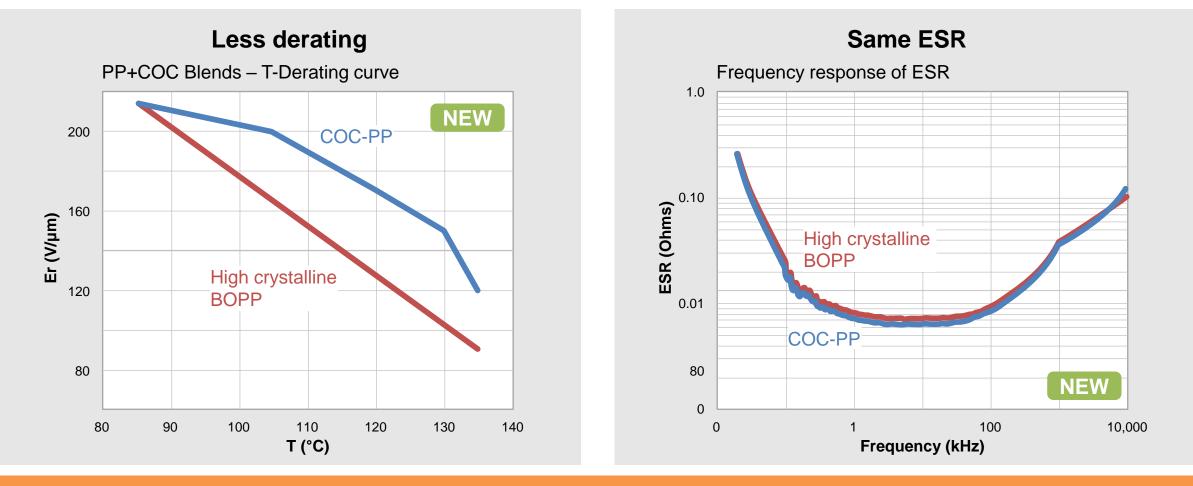
## New material blend for high temperatures



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### Improved performance at high temperatures



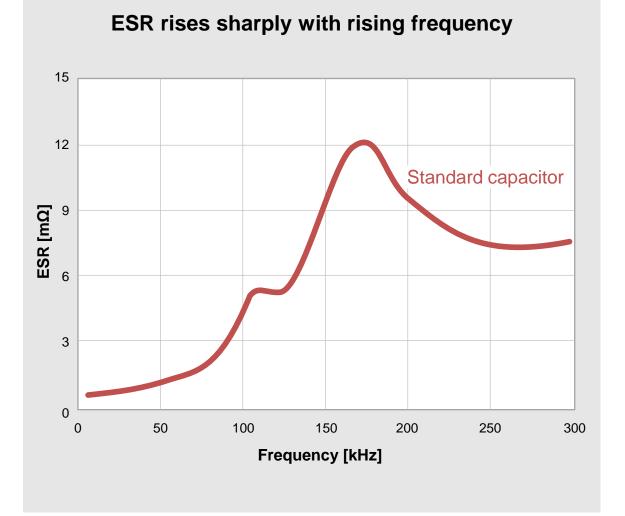
**Best of both worlds** 

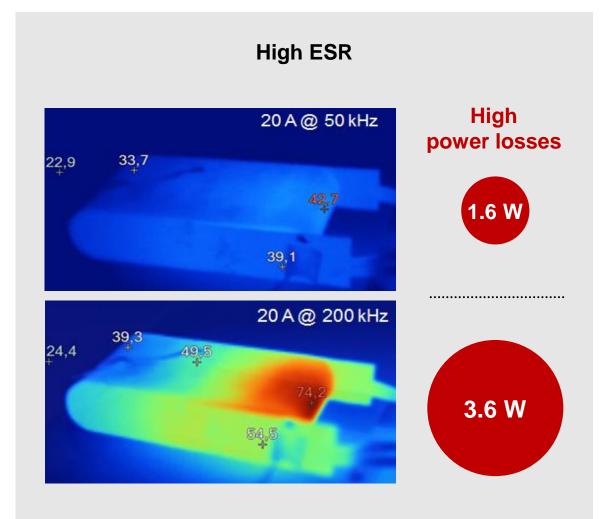
 Aging and failure mechanism similar to BOPP

- Similar self-healing properties
- Stable performance at up to 125 °C

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## Standard power capacitors have unfavorable ESR characteristics





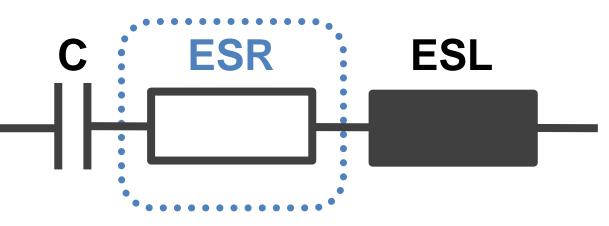
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## **Root causes of increasing ESR**

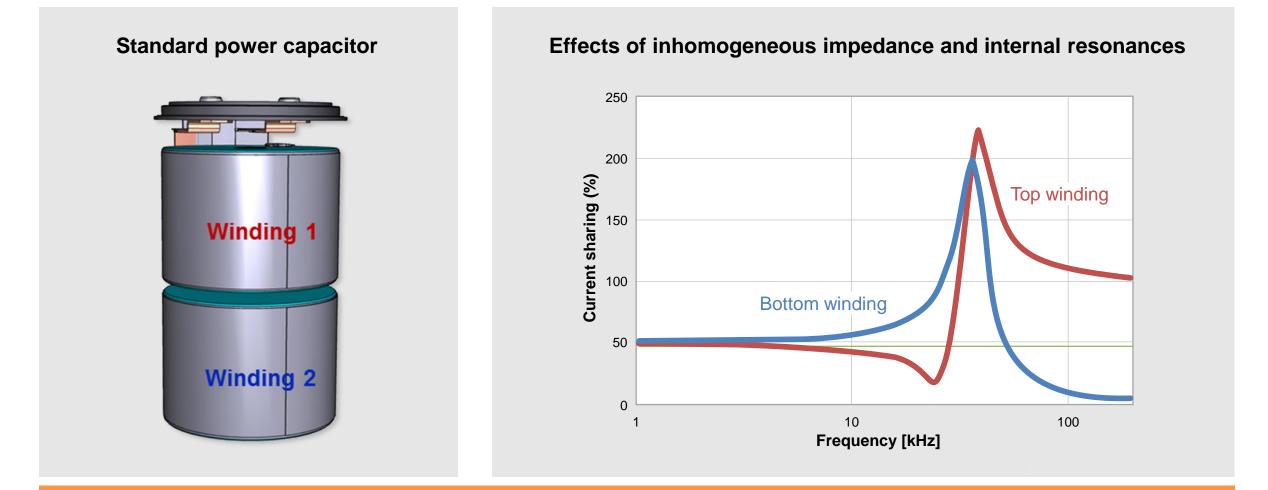
- Inhomogeneous impedance and internal resonances
- Negative electromagnetic interaction
- Winding geometry and metal profile
- Skin effect

Factors offering most potential for improvement!



#### Power capacitors must be fundamentally redesigned in order to operate reliably at higher frequencies

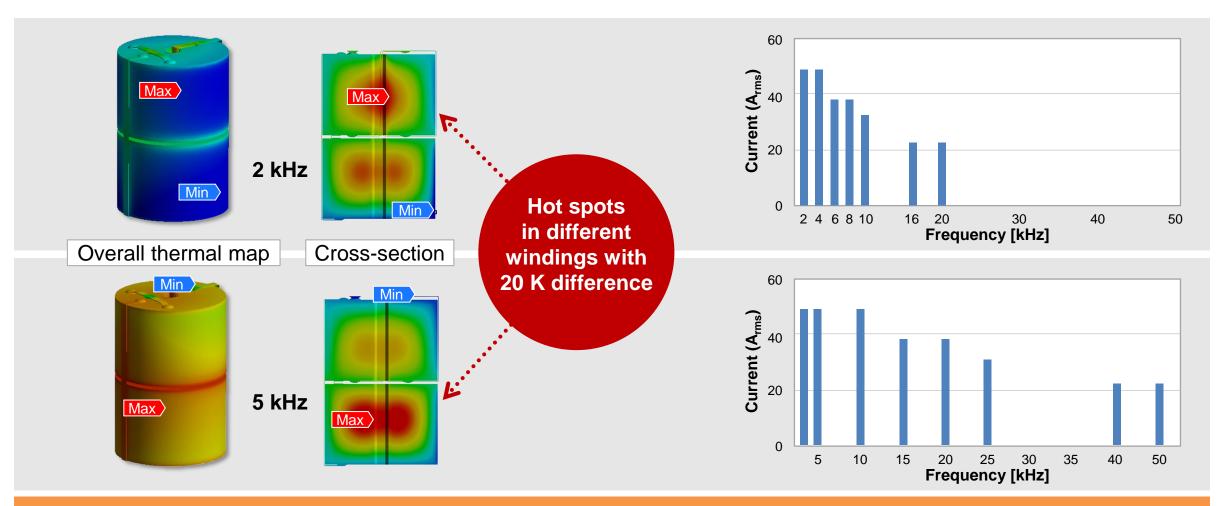
## Standard capacitors are limited at high frequencies



#### Standard capacitors are not ready for high frequencies

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## High ESR has thermal consequences



#### Higher switching frequencies cause unbalanced thermal behavior

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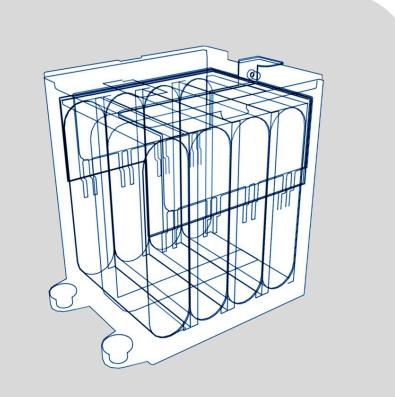


### **Design rules for high-frequency capacitors**

**Same impedance** of all internal capacitive elements above, below and close to capacitor resonance frequency

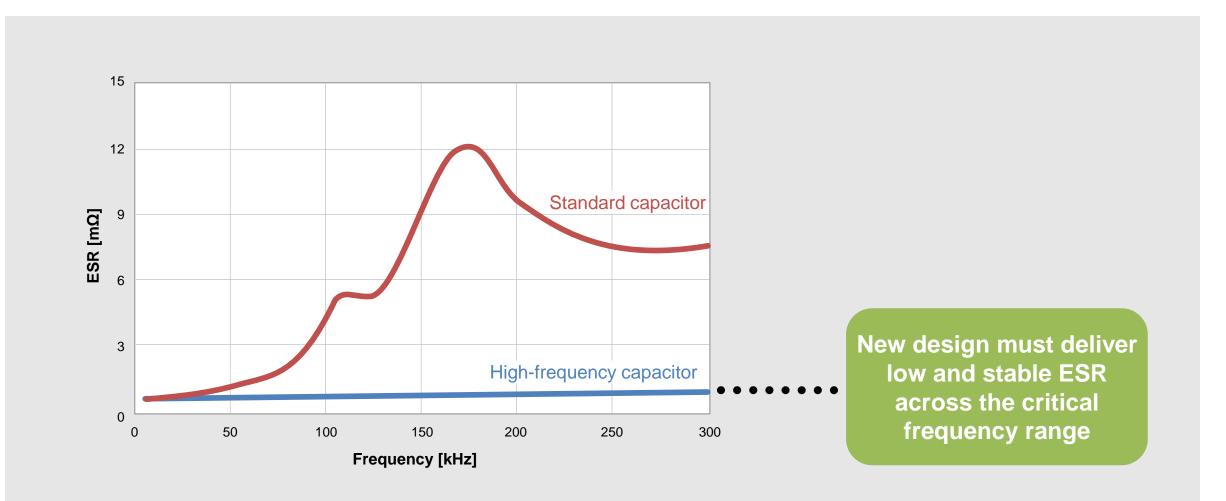
• Avoid negative electromagnetic interactions between conductors (FEA electromagnetic software)

• **Overlapped busbar** from terminals to winding connection point is required in order to minimize the inductance



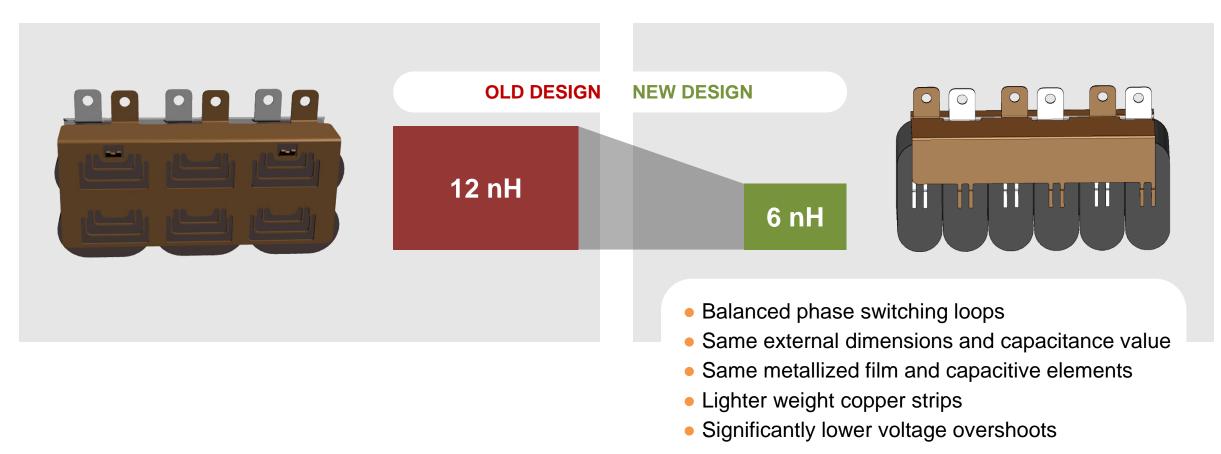
#### Current must be homogeneously distributed at all frequencies

## Design of high-frequency capacitors focused on low ESR





## **Optimized design enables lowest ESL**



#### Makes snubber capacitors unnecessary in most cases

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## Introducing the new Modular film DCR series Under development

#### Ready for standard DC-Link optimization

- High energy density
- Voltage range from 900V to 2400V:
  - Case 1: from 2100µF@900V to 340µF@2400V
  - Case 2: from 3700µF@900V to 600µF@2400V
- Modular concept for parallelization
- Operating temperature: +85°C
- Frequency operation range up to 100 kHz
- Low ESR vs frequency
- Snubber avoidance / low voltage overshoot
- Low ESL 14 nH
- Dimensions:
  - Case 1: 205 x 170 x 90 mm (l x h x w) 3.7kg
  - Case 2: 220 x 215 x 115 mm (l x h x w) 6.1kg
- Resin-filled plastic case
- EN 45545 HL3 R23 (fire and smoke)

Expected release: 2020 Q2 Samples: available under request





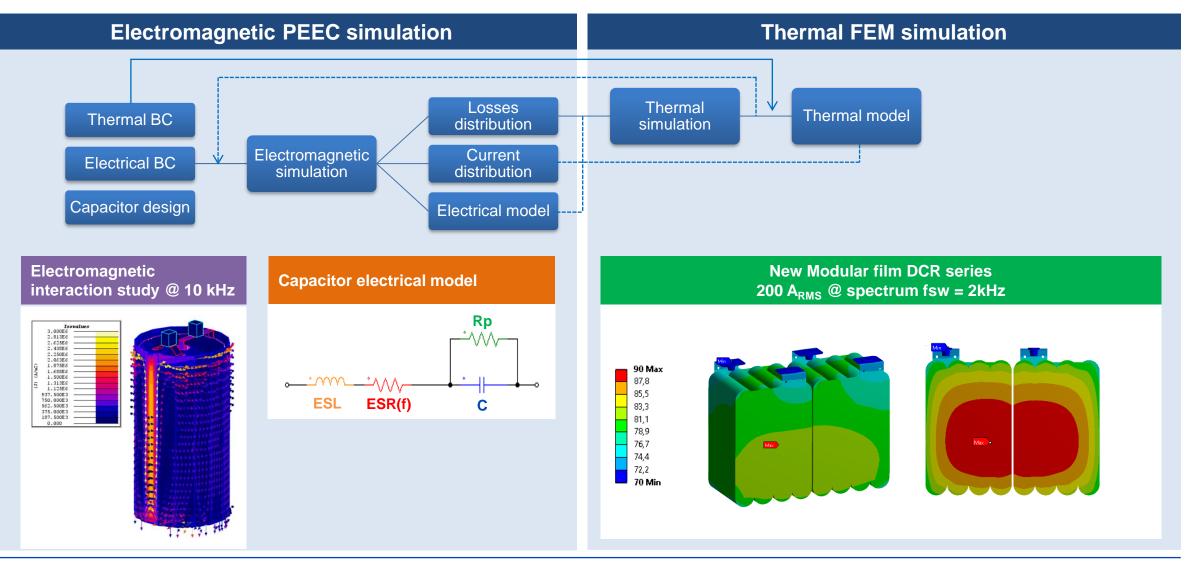
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NEW





## Electromagnetic & thermal simulation Standard Product – Customized solution



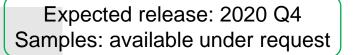
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## Introducing the new HF Modular film DCR series Under development

## Fully compatible with SiC and advanced Si semiconductors

- High power density
- Suitable for higher ambient temperatures
- Suitable for fast transients (dV/dt) and ringing effects
- Modular and suitable for parallel connection
- Snubber avoidance / low voltage overshoot
- Compact and lightweight, enables lighter cooling system





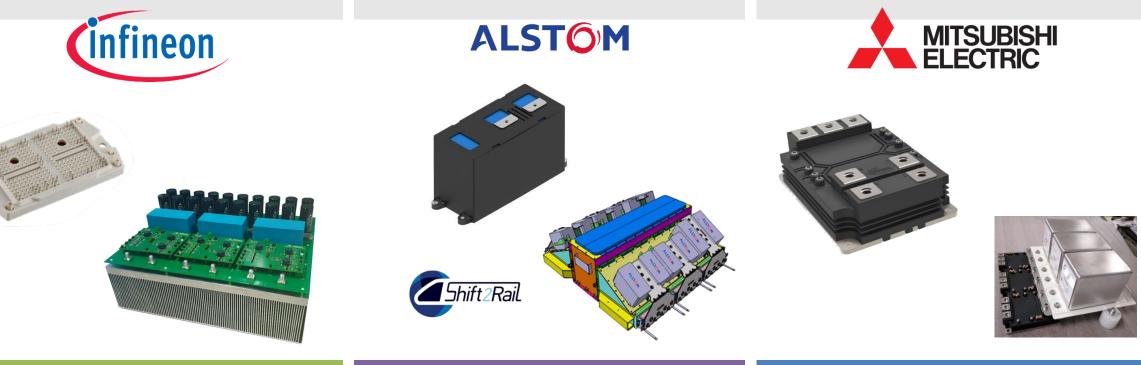
- Operating temperature
  - Standard polypropylene: +105 °C
  - Advanced COC-PP dielectric: +125 °C (in development)

**Attracting Tomorrow** 

- 560 Vdc / 1520  $\mu F$  to 2280Vdc/ 175  $\mu F$
- Frequency operation range up to 2 MHz
- Extremely low ESR vs frequency
- ESL of 16 nH with 1 pair of terminals
- High current density of up to 206 A/mF @ 560
  Vdc and 1286 A/mF @ 2280Vdc
- Compact dimensions (2 sizes):
  - 210 x 130 x 70 mm (l x h x w) 2.8kg
  - 210 x 130 x 95 mm 3.1kg
- Resin-filled plastic case
- EN 45545 HL3 R23 / HL2 R22 (fire and smoke)

#### **Applications** Traction, industrial drives, renewable power

## Selected development projects with new HF modular film capacitor series



#### Infineon Technologies AG:

- Solar 1500V Demonstrator
- Easy 3B module: 1200V TRENCHSTOP<sup>TI</sup> IGBT7 + 1200V CoolSiC<sup>TM</sup> MOSFET
- **TDK Electronics:**
- Hybrid DC-Link capacitor: New HF film PCB+ aluminum electrolytic

#### ALSTOM traction converter

- 3.3-kV SiC MOSFET
- New TDK HF film capacitor series

#### **Traction power module (reference)**

**Attracting Tomorrow** 

- Mitsubishi LV100 3.3kV SiC MOSFET
- New TDK HF film power capacitor
- Parallelization
- Extension to Infineon XHP2 (1.7 kV and 3.3 kV): Ongoing

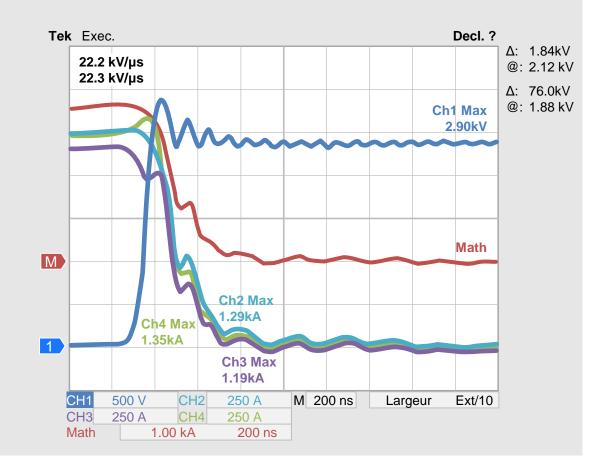
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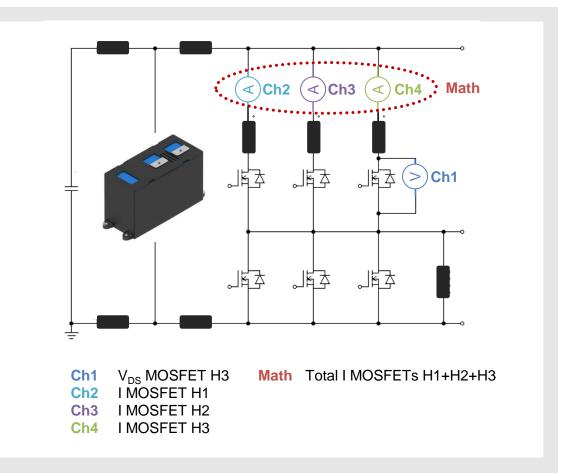
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## HF modular film capacitor series: Ready for hard switching

Attracting Tomorrow







#### New HF film capacitor series with extremely low voltage overshoot and ringing

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manuel.gomez@tdk-electronics.tdk.com

www.tdk-electronics.tdk.com